

Thin Solid Films 359 (2000) 294-294



www.elsevier.com/locate/tsf

## Erratum

## Erratum to "Effect of diatomic islands on step morphological stability of a terrace edge in molecular beam epitaxy" [Thin Solid Films 353 (1999) 174–181]

Senpuu Lin<sup>a,\*</sup>, Chi-Chuan Hwang<sup>b</sup>, Hsin-Sen Chu<sup>c</sup>

<sup>a</sup>Department of Mechanical Engineering, National Lien-Ho College of Technology and Commerce, P.O. Box 12-2, Miao-Li 36012, Taiwan, ROC

<sup>b</sup>Department of Mechanical Engineering, Chung Yuan University, Chung Li 32023, Taiwan, ROC

<sup>c</sup>Department of Mechanical Engineering, National Chiao Tung University, Hsinchu 30050, Taiwan, ROC

Received 14 October 1998; received in revised form 29 April 1999; accepted 30 April 1999

The Publisher regrets that during the final processing of the above article, Republic of China was incorrectly printed as People's Republic of China. We sincerely apologise for this oversight and regret any embarassment caused. The correct affiliations of the authors are as presented above.

PII: S0040-6090(99)01072-X

 $<sup>^{*}</sup>$  PII of original article: S0040-6090-(99)00325-9.

<sup>\*</sup> Corresponding author. Fax: + 886-3-736-4145. *E-mail address*: spuulin@mail.lctc.edu.tw (S. Lin)